

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Ritsuko KAWASAKI et al.

Serial No. 09/651,889

Filed: August 30, 2000

For: SEMICONDUCTOR DEVICE,
 MANUFACTURING METHOD
 THEREOF AND ELECTRONIC
 DEVICE



) Group Art Unit: 2814

) Examiner: D. Farahani

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AMENDMENT

Commissioner of Patents
 Washington, D.C. 20231

Dear Sir:

In response to the Examiner's non-final Office Action dated June 6, 2002, please amend the above-identified application as follows.

IN THE CLAIMS:

Please amend claims 1-3 and 11-16 as follows. The amendments to the claims are outlined in an Attachment to the Amendment using the conventional indication method of bracketing and underlining.

1. (Twice Amended) A semiconductor device comprising a TFT containing an active layer having a channel forming region,
 wherein the channel forming region has a convex portion or a concave portion extending in a channel width direction.